

EPFL MICRONANOFABRICATION ANNUAL REVIEW MEETING

2012: TUESDAY MAY 8TH





WELCOME & THANKS

- Welcome to the 12th edition of the CMi MicroNanoFabrication Annual Review Meeting
- Welcome to the Inauguration Ceremony of the BM building transformations
 - + Including the CMi cleanroom extension
- * Many thanks for your participation
- × 410 participants (30% industry, 40% external)





EVOLUTION OF THE CMI

CMI tools ...











IC

MEMS



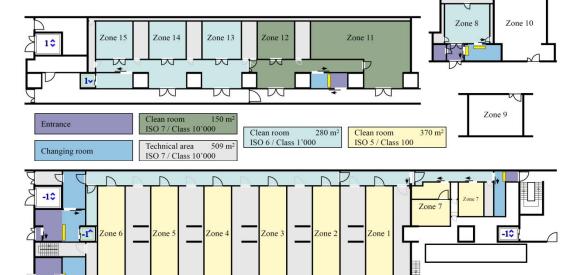






CLEANROOM EXTENSION

× CMi BM+1



CMi BM+1 mainly dedicated to:

- Metrology
- Wet Chemistry
- Photolithography
- × PDMS processing
- Thin films
- Backend activities
- Exploratory processes

× CMi BM-1



CMi BM+1 will be widely used by the Researchers from the Life Sciences and the Basic Sciences





CLEANROOM EXTENSION



Many tools already in operation like:

- × PDMS facility
- Versatile photolithography area
- * Flexible wet chemistry lab





CLEANROOM EXTENSION





Dressing rules in CMi BM+1

Dressing rules in CMi BM-1





NEW CONCEPT

- * Much more than a cleanroom extension ...
- Adaptation program of the CMi to fulfill the new needs for research and education
- Allow access to a broader technology base
- Increase flexibility of use, allow for quick and easy processing (open 24/7)
- Offer more freedom (but also less support)
- Further promote collaborations and sharing of know-how
- Adapt the cost structure to the new needs
- × Offer extra space for teaching lab in nano & bio
- This is an add and not a degradation of the existing CMi



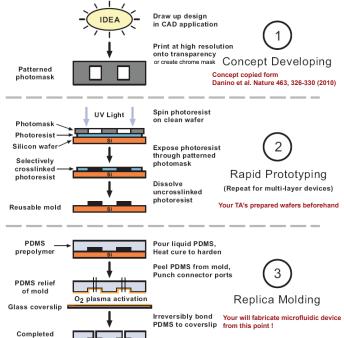
NEW TEACHING LAB

Advanced BioEngineering Methods Laboratory (master in bioengineering, Prof. Radenovic) Actually 4 teaching Labs in CMi:

- x 1° Radenovic/Guiducci
- 2° Gijs/Brugger
- × 3° Muralt
- × 4° Renaud

Integration of Microfluidics and Microscopy for Cellular Analysis

Draw up design in CAD application













× ALD



× Accepted on 18.02-2011





× Grinder

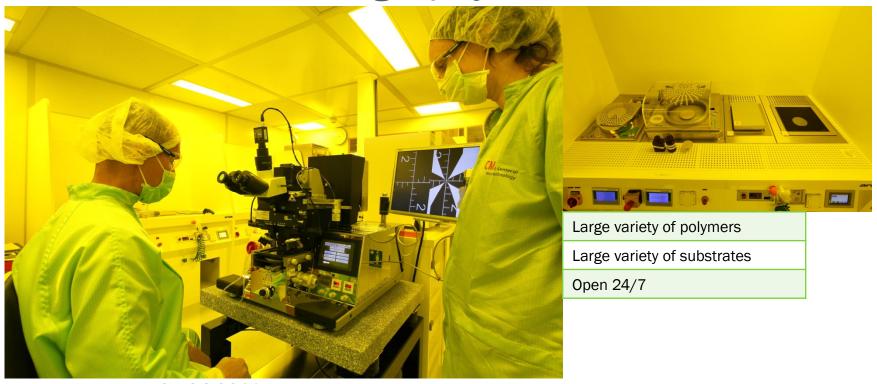


× Accepted on 06.05-2011





Versatile Photolithography area



× Accepted on 05.04-2011



- × PDMS processing line including a hole puncher
- ★ Thermal & uv Imprinter
- × Plotter cutter
- Circuit board prototyping tool
- **×** Laminator
- Thermal evaporator
- × Vacuum furnace

× ...

Total Inventory in 2011			
Scientific Equipment Level -1	22 MCHF		
Scientific Equipment Level +1	1 MCHF		
Total	23 MCHF		





REQUESTED BUDGET FOR 2011

- × SEM
- × AFM
- Mechanical Profiler
- Sputtering tool for metals
- Elphy Multibeam FIB & SEM pattern generator
- ★ EBEAM 10 position airlock
- × RIE ICP*
- Sputtering tool for oxides*

** = in collaboration with LEPA

* = in collaboration with ICMP

- Nanomaterial Printing Platform**
- ... please continue to tell us your needs



USERS IN 2010

S	TI	SB	SV & IC	EXT	COMF	PANIES
STI-CMI	STI-IMT-LOA	SB-CIME	SV-GHI-UPKIN	EXT-CEA	EXT-Abionic	EXT-Sensimed
STI-CBT-LBO	STI-IMT-LPM	SB-ICMP-LASPE	SV-IBI1-LMBM1	EXT-EMPA	EXT-Adv-Silicon	EXT-Sigatec
STI-IBI2-CLSE1	STI-IMT-LSRO1	SB-ICMP-LOEQ	SV-IBI1-UPDEPLA	EXT-FEMTO	EXT-Ayanda	EXT-SilMach
STI-IBI2-LBEN	STI-IMT-NAM	SB-ICMP-LPMC	SV-IBI1-UPLUT	EXT-HESVS	EXT-Biocartis	
STI-IBI2-LBNC	STI-IMT-OPT	SB-ICMP-LPN		EXT-HUG	EXT-Bruker	
STI-IEL-LANES	STI-IMT-SAMLAB	SB-ICMP-LPQM1		EXT-UNIGE	EXT-Colibrys	
STI-IEL-LSM	STI-IMX-LC	SB-IPEP-LPHE1			EXT-Debiotech	
STI-IEL-NANOLAB	STI-IMX-LMM	SB-IPSB-LCB			EXT-EXALOS	
STI-IMT-ESPLAB	STI-IMX-LMSC	SB-IPSB-LPMV			EXT-Flowdit	
STI-IMT-LMIS1	STI-IMX-LTC	SB-ISIC-LEPA			EXT-Icoflex	
STI-IMT-LMIS2		SB-ISIC-LPI			EXT-Intersema	
STI-IMT-LMIS3			IC-ISIM-LSI1	EXT-CSEM 12	EXT-Karmic	
STI-IMT-LMIS4					EXT-Leister	
STI-IMT-LMTS					EXT-Nanoworld	
STI-IMT-LO					EXT-Rolex	
187	(25)	35 (11)	20 (5)	20 (7)	23	(18)

Total: 285 users from 48 labs (and 18 companies)



Ecole Polytechnique Fédérale de Lausanne

ABSTRACTS

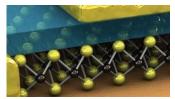
× 181 abstracts

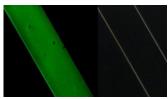












Published on EPFL homepage

- 13.09.2010 The pocket projector is a reality!
- × 01.10.2010 Engineering Life a new generation of students emerges
- **x** 28.10.2010 Energy saving devices (Steeper project)
- x 12.11.2010 All optical transistor
- **★** 30.01.2011 A material to revolutionize electronics
- 14.03.2011 EPFL reinvents the liquid crystal display







CMi EPFL Center of

PROJECTS AT

THE EPFL CENTER OF MICRONANOTECHNOLOGY

May 2011

http://cmi.epfl.ch

CONCLUSIONS

- Since its opening in 1999, CMi has constantly increased its volume of activity
- CMi is anticipating the needs for Research & Education
- Many success stories are built inside CMi
- CMi is well prepared for the future



PROGRAM





The highest value of the CMi is its Users \dots



PROGRAM

×	10h20-10h40	B. Vigna (Group VP & General Manager STMicroelectronics), From Motion Sensors to iNEMO™
×	10h40-11h00	S. Lacour (http://lsbi.epfl.ch/), Micro-Nanofabrication on Elastomeric Substrates
×	11h00-11h20	Y. Leblebici (http://lsm.epfl.ch/), Heterogeneous System Integration: Opportunities and Technologies for Platform Development
×	11h20-11h45	Break
×	11h45-12h00	B. Vianay (http://lcb.epfl.ch/), Adhesive Protein Micropatterning for Constraining Cell Spreading to Adopt Geometrical Features
×	12h00-12h15	V. Cadarso (http://lmis1.epfl.ch/), Non-Conventional Methods for Polymer Processing
×	12h15-12h30	L. Forro (http://lpmc.epfl.ch/), From Carbon Nanotubes to Topological Insulators in Nanofabrication
×	12h30-12h35	Ph. Gillet (Vice-President for Academic Affairs), Message from the Vice-President
×	12h35-13h00	D. Psaltis (Dean of STI), Micro and Nanotechnology at the School of Engineering
×	13h00-14h30	Opening Ceremony of BM Building Transformations with our President Patrick Aebischer
		Lunch & Technical Exhibition
		Place: in front of BM building (or in SG 294.22 if weather is bad)
×	14h30-14h45	R. Martinez-Duarte (http://lmis4.epfl.ch/), Microfabrication of Glass-like Carbon and Related Applications
×	14h45-15h00	R. Lockhart (http://www.csem.ch/), Fully Programmable Micro Diffraction Gratings
×	14h30-15h30	Break
×	15h30-15h45	W. Song (http://lo.epfl.ch/), Optofluidics: From Micro to Nanoscale
×	15h45-16h00	J. Baborowski (http://www.csem.ch/), Packaging of Silicon Resonators
×	16h00-17h00	Cocktails & Poster Session





ENJOY THE CONFERENCE

- Enjoy the conference!
 - + WiFi Access
 - × See last page of the Participants'List
 - * Username: x-cmi1
 - * Password: mimlob84
 - ★ Type d'accès: enclair (SSID public-epfl)



